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PATENT 9/25/02  
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**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicants : Yoshitaka TSUNASHIMA et al.

U.S. Serial No. : 09/803,265

Filing Date : March 9, 2001

For : **SEMICONDUCTOR DEVICE HAVING A GATE  
INSULATING FILM STRUCTURE INCLUDING AN  
INSULATING FILM CONTAINING METAL, SILICON AND  
OXYGEN AND MANUFACTURING METHOD THEREOF**

Examiner: : Jack S. J. Chen

Group Art Unit : 2813

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TECHNOLOGY CENTER 2800

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New York, New York 10151

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Assistant Commissioner for Patents, Washington, DC 20231, on August 30, 2002.

Grace L. Pan, Reg. No. 39,440

Name of Applicant, Assignee or Registered Representative



Signature

August 30, 2002

Date of Signature

**RESPONSE**

Assistant Commissioner for Patents  
Washington, D.C. 20231

Sir:

In response to the August 2, 2002 Office Action, which sets a one-month period for response, making this response due September 3, 2002 (since September 2 is a holiday), Applicants provisionally elect, without traverse, the invention of Group II, upon which claims 1 to 5, 12 and 13 read, for further prosecution, without prejudice.